NEWS Meeting – September 25, 2017

NEWS Work Package 7

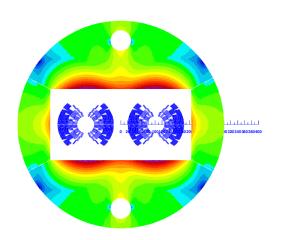
Advanced Superconducting Technologies for Particle Accelerators

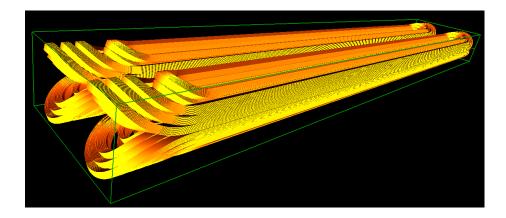
Emanuela Barzi, Fermilab



FNAL-INFN 16 T Accelerator Dipole

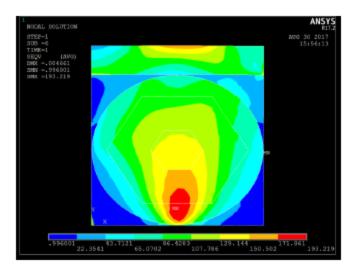
- The challenge for the INFN-FNAL collaboration is pushing the <u>design limit</u> of these magnets to their superconducting potential (or <u>Short Sample limit</u>, <u>SSL</u>). For a 16 T Nb₃Sn dipole, the design limit needs to be at least 17 T. → The team will need to investigate creative strain management options.
- However, first one has to solve the problem of why Nb₃Sn accelerator magnets typically reach at best 90% of SSL. <u>This means that the conductor is only carrying 70% of its critical current I_c.
 </u>





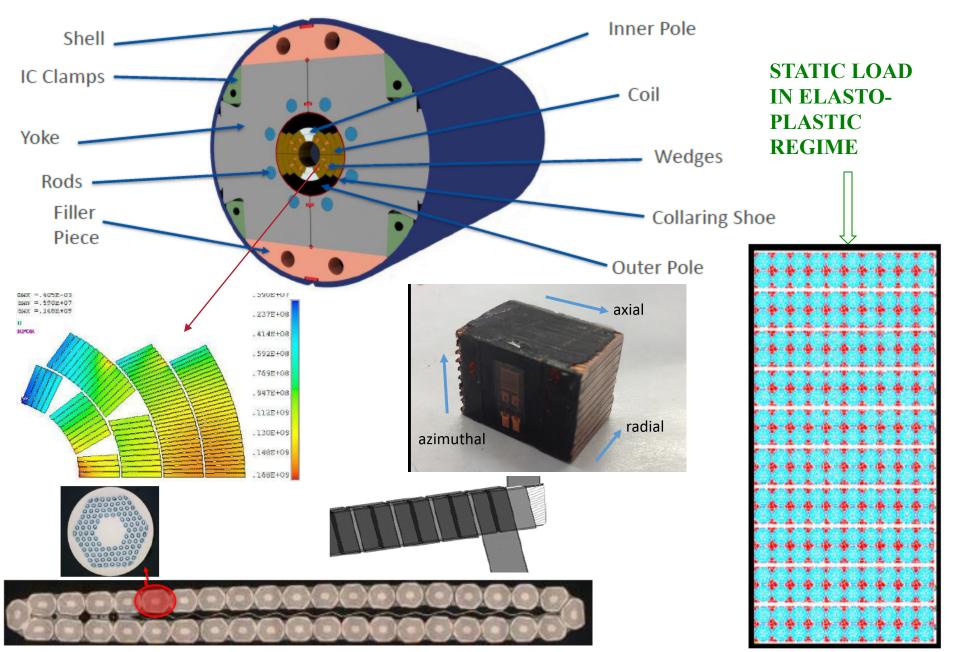
Necessary Step is

Understand how stresses and strains are distributed inside the superconductor

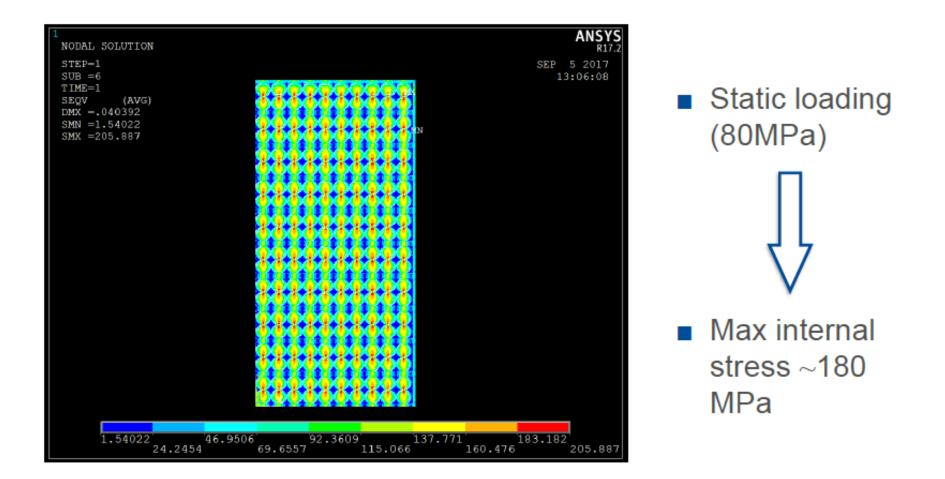


Apply strain and stress management techniques

Sub-Modeling at 300K



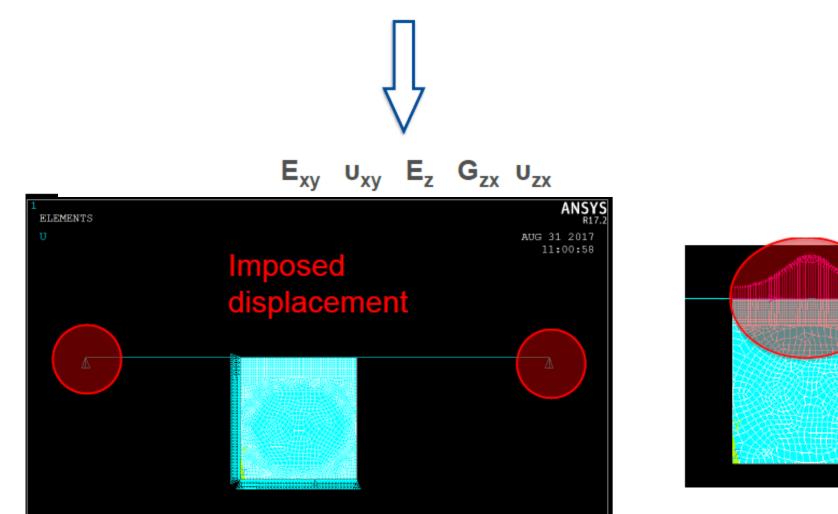
Nb₃Sn Thin Films on Nb –New Results (1)



The maximum obtained T_c was 17.68 K and the B_{c20} ranged between 22.5 T and 23.8 T

Next Steps

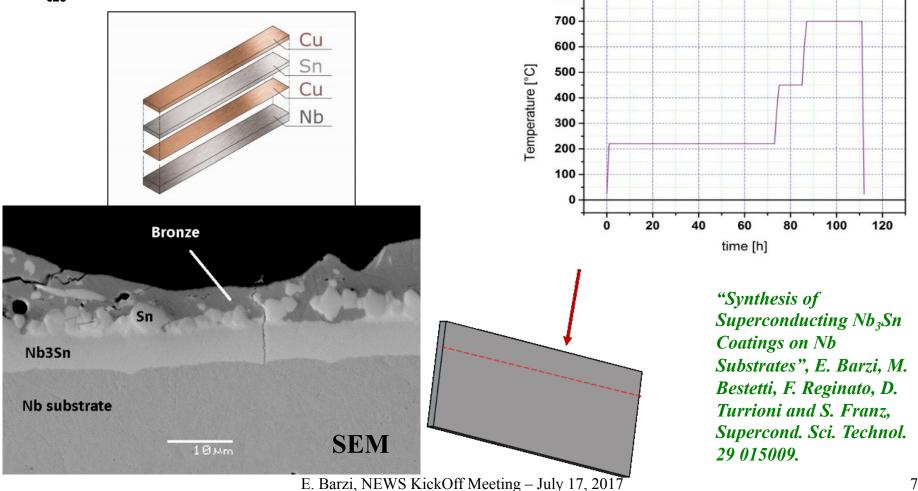
 Mechanical characterization of the composite material strands (Cu+Nb₃Sn) + epoxy + insulation in the simplest assumption of anisotropic material, i.e. <u>Orthotropic transversally isotropic</u>



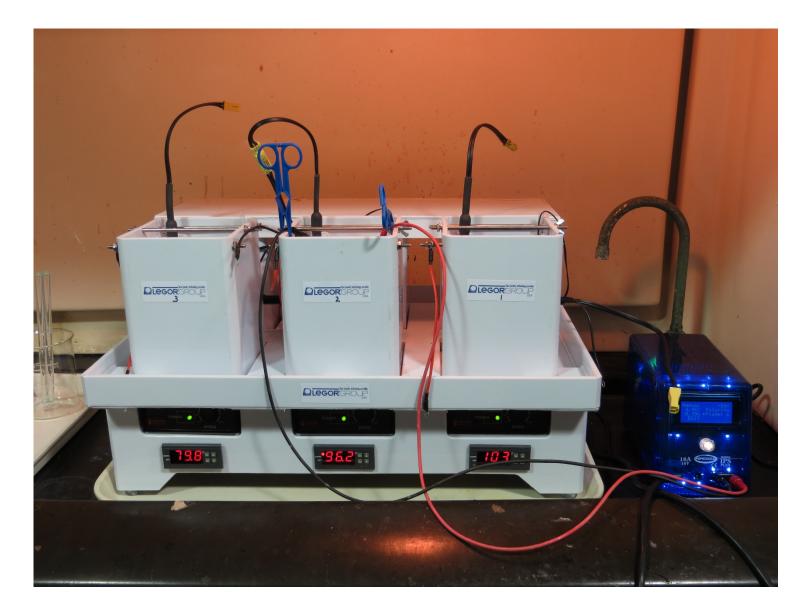
Nb₃Sn Thin Films on Nb

* An electro-chemical deposition technique to produce Nb₃Sn coatings was developed in the last few years by FNAL and the Politecnico di Milano.

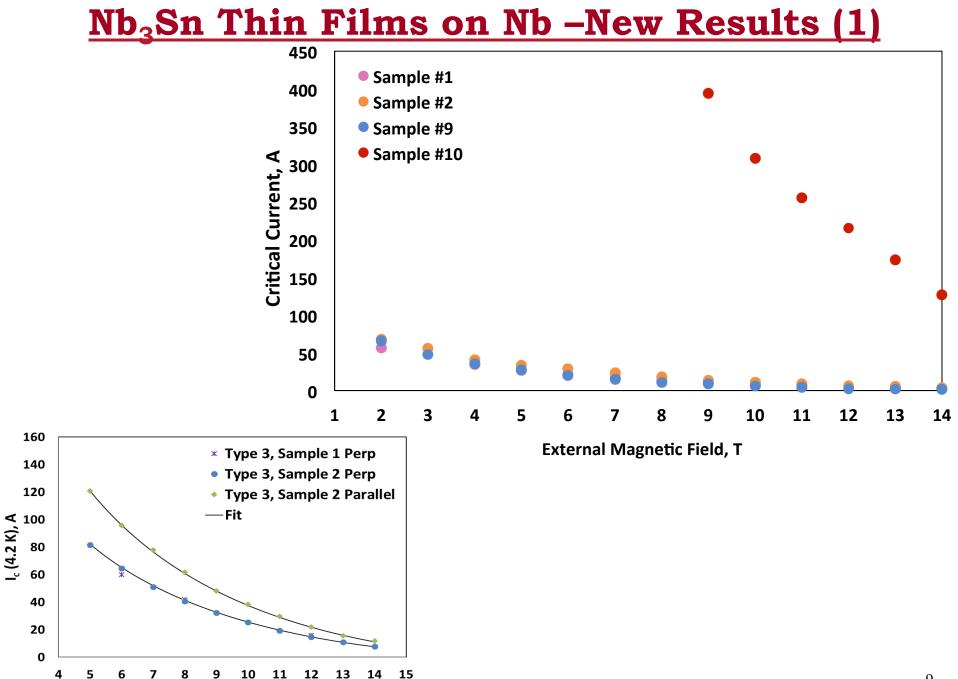
* The Nb₃Sn phase is obtained by electrodeposition of Sn layers and Cu intermediate layers onto Nb substrates, followed by high temperature diffusion in inert atmosphere. In 2014, Nb₃Sn superconducting samples between 5.7 and 8.0 μ m in thickness were produced with a maximum obtained T_c of 17.68 K and B_{c20} ranging between 22.5 T and 23.8 T.



New FNAL Setup for Electro-chemical Deposition

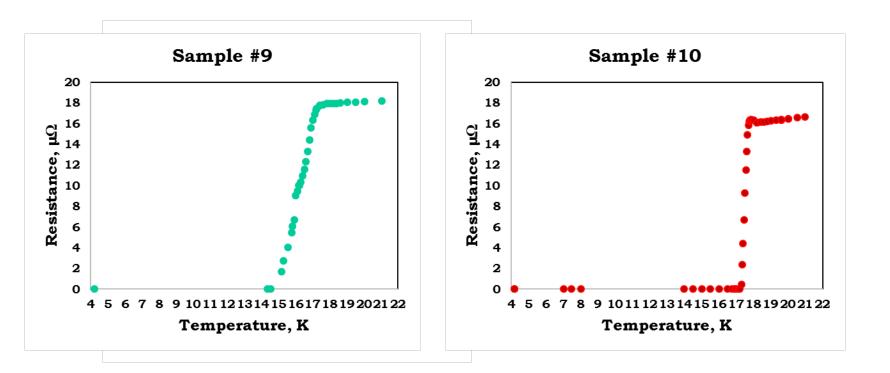


E. Barzi, NEWS KickOff Meeting – July 17, 2017



B. T

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First Goal for Superconducting Nb₃Sn Films was

Reproduce the original recipe. Achieve:

- the best uniformity of the deposit across the surface
- the best purity
- improve the adhesion of the film
- eliminate Nb oxides at the interface

Next Steps

SEM analyses